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YS

**NONFERROUS METALS INDUSTRY STANDARD OF THE
PEOPLE'S REPUBLIC OF CHINA**

YS/T 718-2009

**Flat magnetizing sputtering target. Niobium target for optical
coating**

平面磁控溅射靶材光学薄膜用铌靶

(English Translation)

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What this standard covers

This standard specifies the optical thin film planar magnetron sputtering of niobium target requirements, test methods, inspection rules, marking, packaging, transportation, storage and purchase order (or contract) content. This standard applies to optical thin film planar magnetron sputtering niobium target.

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